



PATENT APPLICATION
Attorney Docket No.: Q60118

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Kazuyoshi MIZUTANI et al.

Appln. No.: 09/615,708

Confirmation No.: Not yet assigned

Group Art Unit: 1752

Filed: July 13, 2000

Examiner: C. Hamilton

For: BOTTOM ANTI-REFLECTIVE COATING MATERIAL COMPOSITION AND
METHOD FOR FORMING RESIST PATTERN USING THE SAME

SUPPLEMENTAL AMENDMENT

Commissioner for Patents
Washington, D.C. 20231

Sir:

Please amend this application as follows:

IN THE CLAIMS:

Please enter the following amended claims:

Claim 19. (Amended) A bottom anti-reflective coating material composition as claimed in claim 12, wherein said polymer light absorbent contains from 2 to 50 wt% of a repeating structural unit represented by formula (XXVII) of claim 18 where B_1 is a group obtained by the reaction of a group represented by $-CONHCH_2OH$, $-CONHCH_2OCH_3$, $-CH_2OCOCH_3$, $-C_6H_4(OH)CH_2OH$, $-C_6H_4(OH)CH_2OCH_3$ or $-CONHC(CH_3)_2CH_2COCH_3$, with formalin.

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